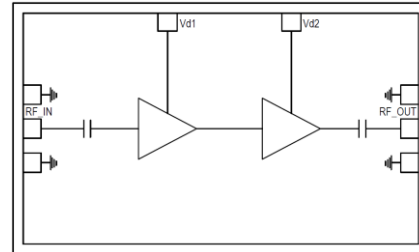


20 – 40 GHz Low Noise Amplifier

Features

- ◆ Frequency Range : 20 - 40GHz
- ◆ Nominal Gain : 12dB
- ◆ Noise Figure : 3.0dB
- ◆ Output P1dB : 6dBm
- ◆ Self-bias operation
- ◆ DC decoupled Input and Output
- ◆ Chip Dimension: 1.38mm x 1.13mm x 0.1mm

Functional Diagram



Typical Applications

- ◆ Radar
- ◆ Military
- ◆ Test Equipment and Sensors.

Description

The ASL1028 is a Low Noise Amplifier operating in 20.0 – 40.0 GHz frequency range. The LNA uses two stages of amplification and provides 12dB of gain with noise figure of less than 3dB having input & output return losses better than 7dB. The LNA has P1dB of 6dBm over the entire operating frequency band and operates either on +3V or +4V DC supply with a current consumption of 28mA (typ)@3V operation. The circuit grounds on the die are provided through vias to the backside metallization.

Absolute Maximum Ratings¹

Parameter	Absolute Maximum	Units
Positive DC voltage	+6	V
RF input power	+20	dBm
Operating Temperature	-55 to +85	°C
Storage Temperature	-65 to +150	°C

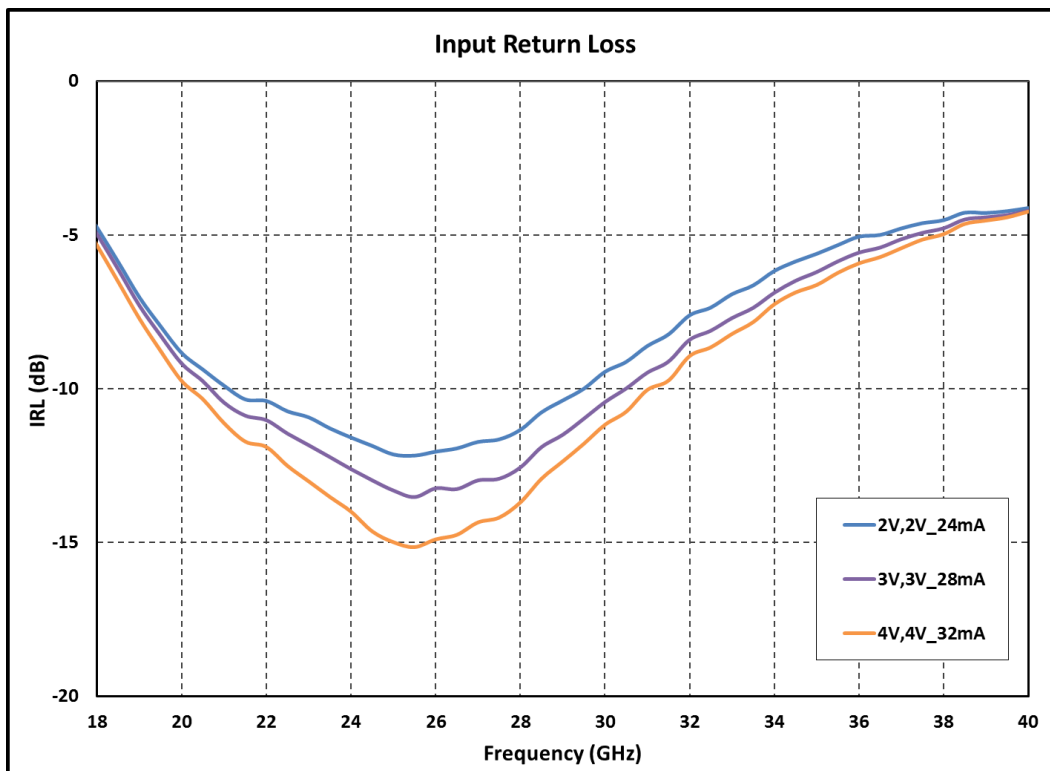
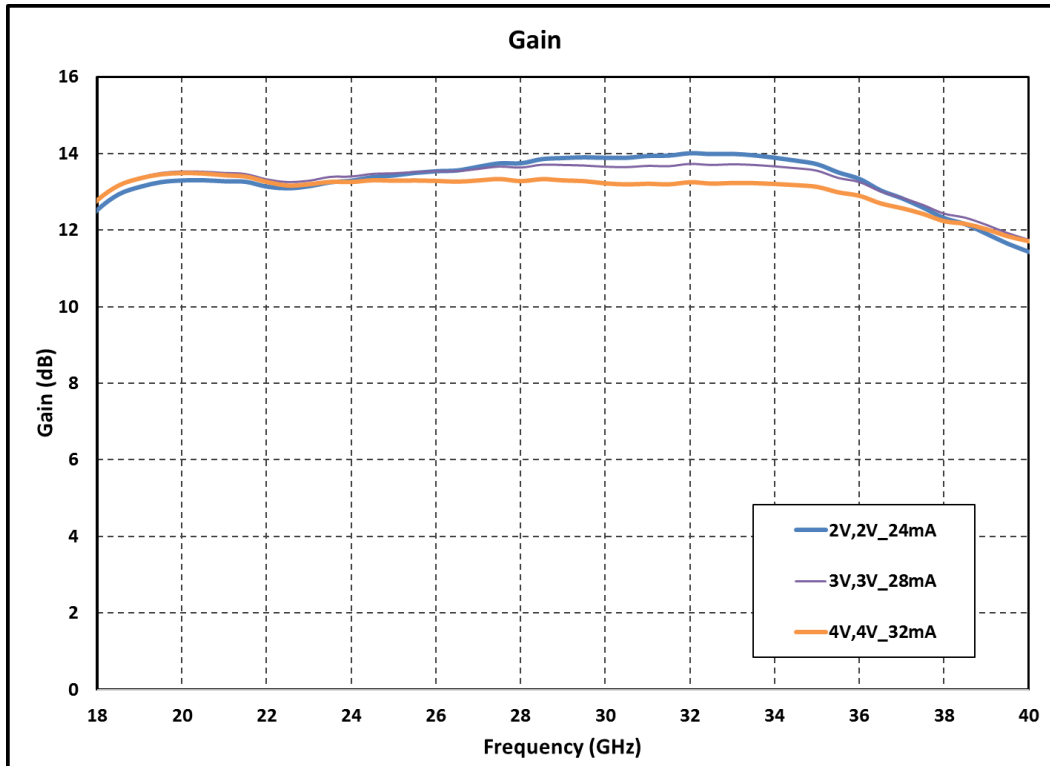
1. Operation beyond these limits may cause permanent damage to the component

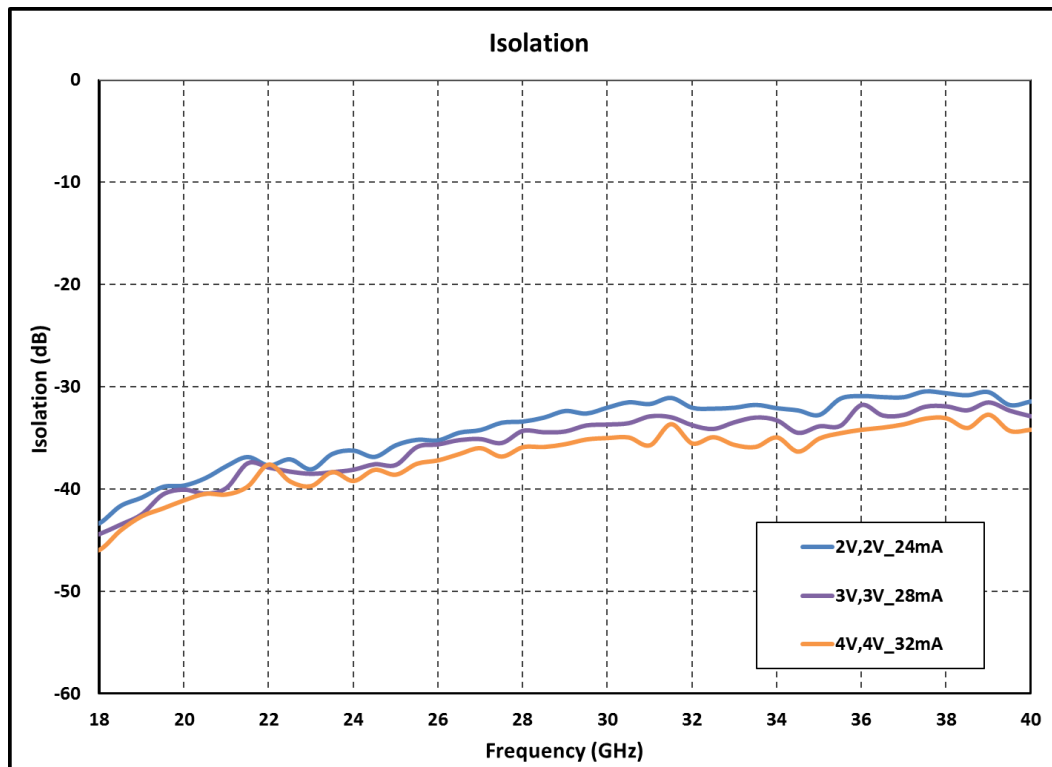
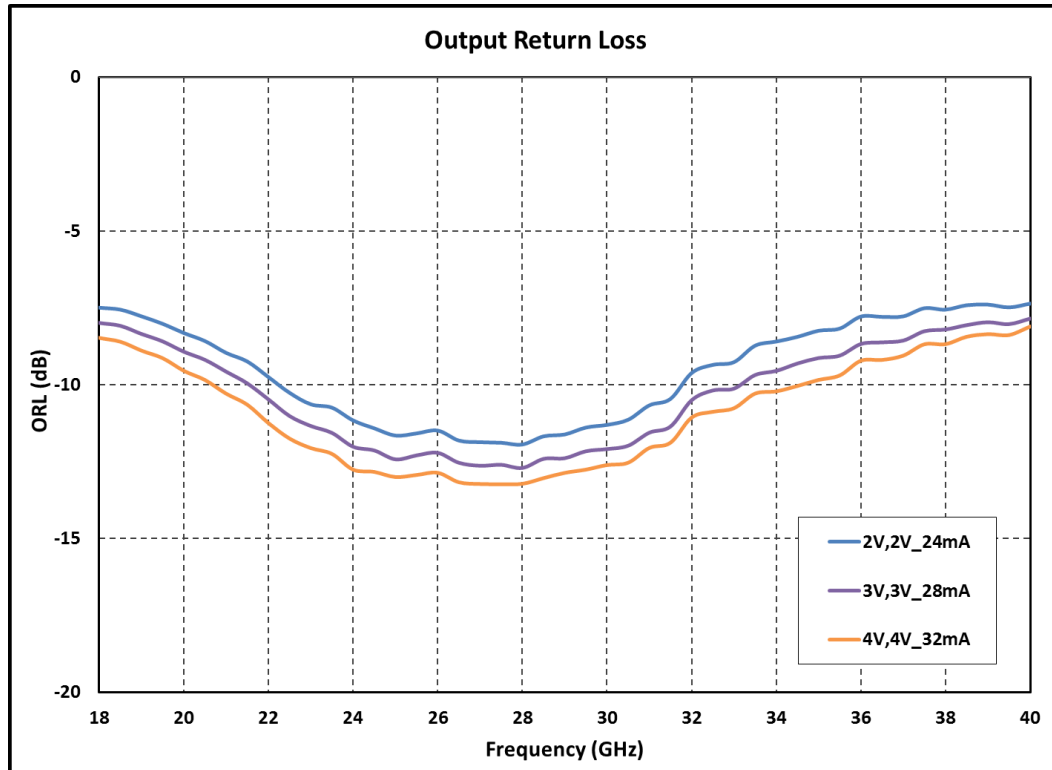
Electrical Specifications @ $T_A = 25\text{ }^\circ\text{C}$, $Z_o = 50\Omega$,

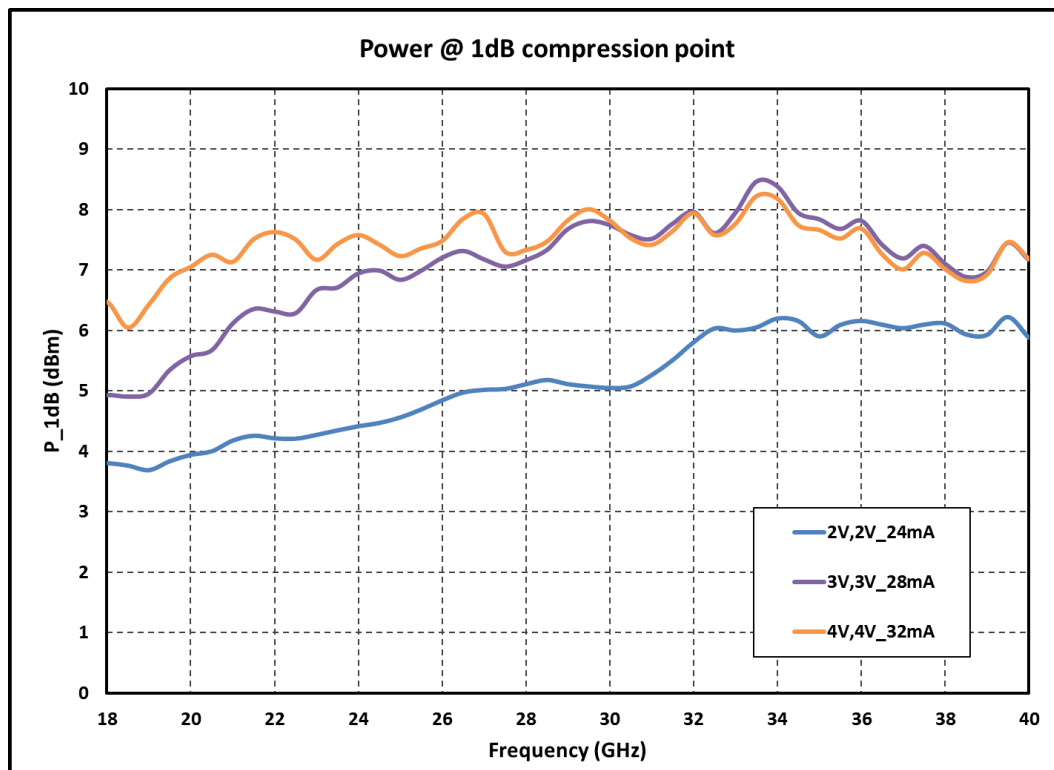
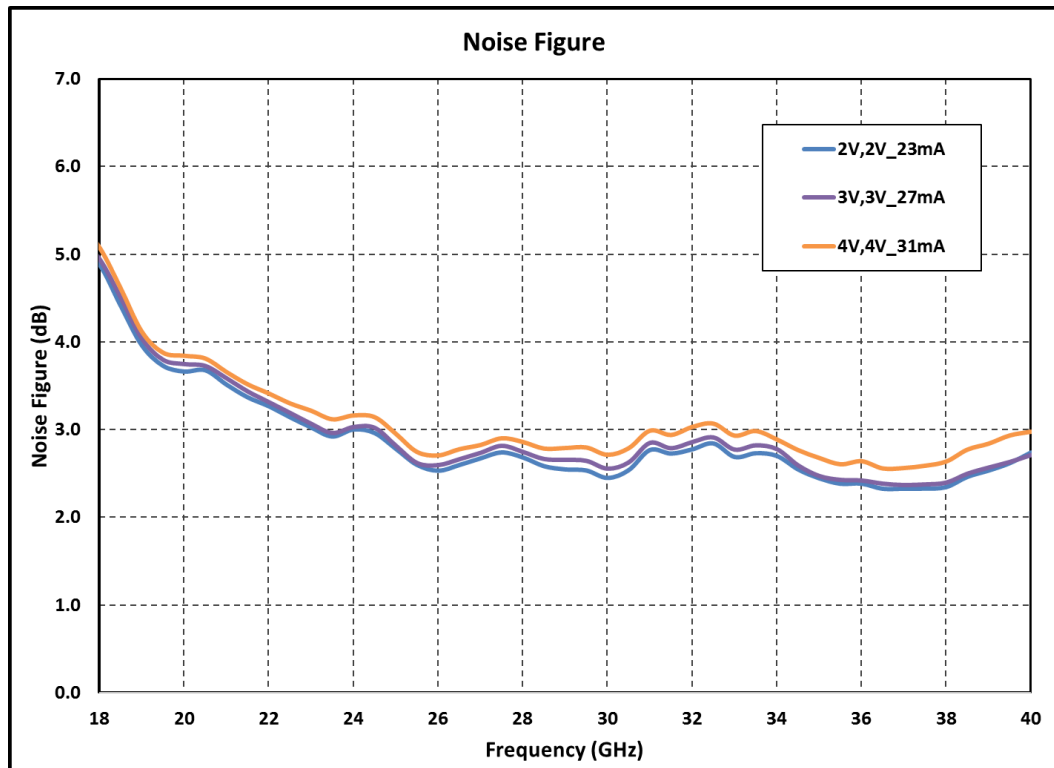
Parameter	Min.	Typ.	Max.	Units
Frequency	20		40	GHz
Gain	-	12	-	dB
Gain Flatness	-	± 1	-	dB
Noise Figure	2.5	3.0	4.0	dB
Input Return Loss	-	7	-	dB
Output Return Loss	-	7	-	dB
Output Power (P1dB)		6/7 ⁽²⁾		dBm
Supply Voltage		3		V
Supply Current		28		mA

Note:

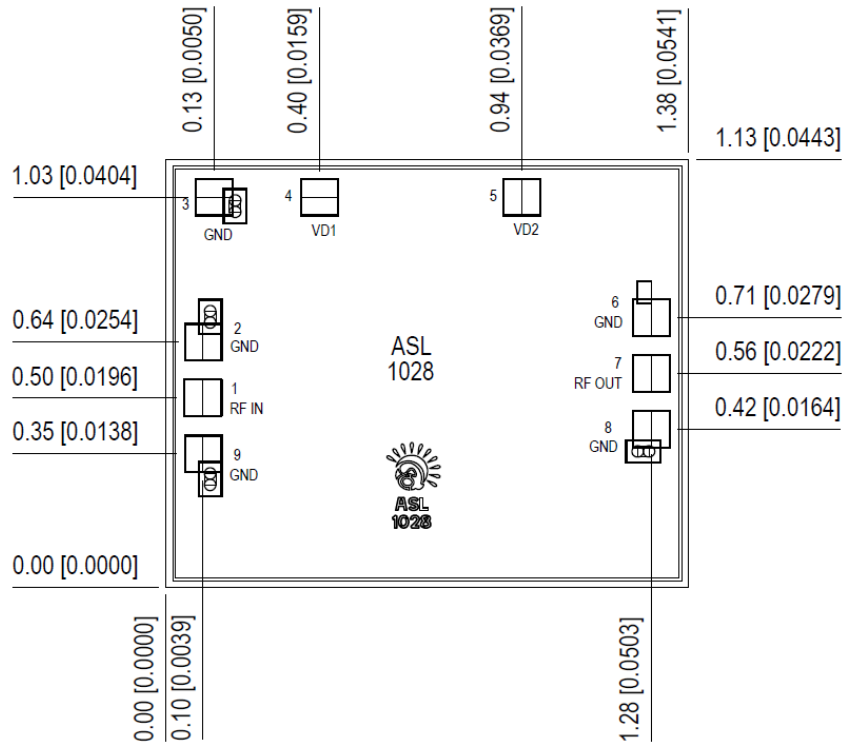
1. The above mentioned electrical specifications are measured On-Wafer
2. 7dBm P1dB can be achieved for drain supply voltage at 4V.

On-wafer Probed data
 $V_{d1} = V_{d2} = 3V$, Total Current = 28 mA, $T_A = 25\text{ }^\circ\text{C}$


On-wafer Probed data
 $V_{d1} = V_{d2} = 3V$, Total Current = 28 mA, $T_A = 25^\circ C$


On-wafer Probed data
 $V_{d1} = V_{d2} = 3V$, Total Current = 28 mA, $T_A = 25\text{ }^\circ\text{C}$


Mechanical Characteristics



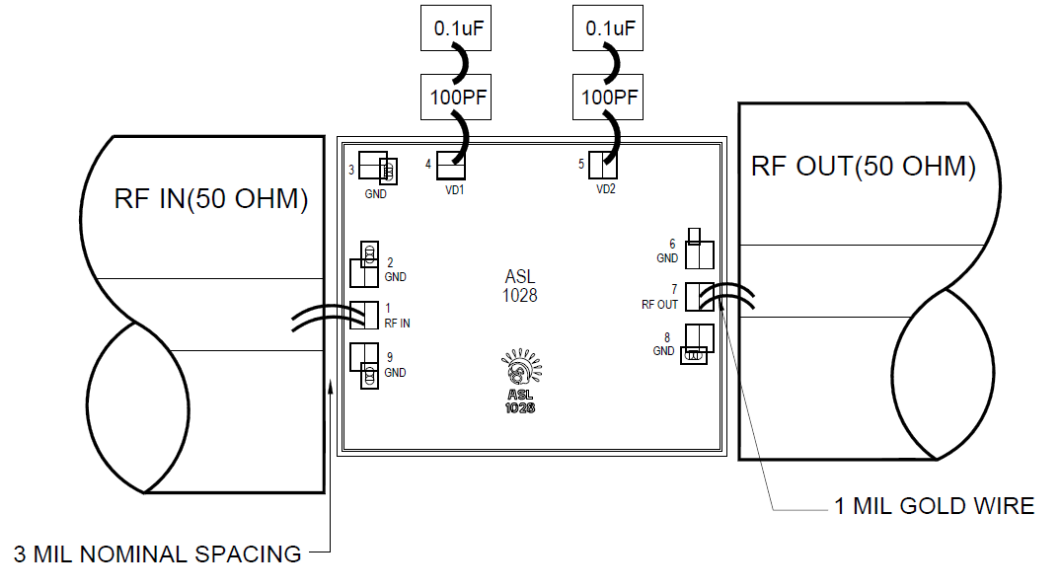
Units: millimeters (inches)

All RF and DC bond pads are 100µm x 100µm

Note:

- | | | |
|--------------------------|---|--------|
| 1. Pad no. 1 | : | RF in |
| 2. Pad no. 4 | : | Vd1 |
| 3. Pad no. 5 | : | Vd2 |
| 4. Pad no. 7 | : | RF OUT |
| 5. Pad no. 2, 3, 6, 8, 9 | : | GND |

Recommended Assembly Diagram



Note:

1. Two 1 mil (0.0254mm) bond wires of minimum length should be used for RF input and output.
2. 100pF and 0.1 μ F capacitors may be additionally used as a second level of bypass at the power supplies for reliable operation.

Die attach: For Epoxy attachment, use of a two-component conductive epoxy is recommended. An epoxy fillet should be visible around the total die periphery. If Eutectic attachment is preferred, use of fluxless AuSn (80/20) 1-2 mil thick preform solder is recommended. Use of AuGe preform should be strictly avoided.

Wire bonding: For DC pad connections use either ball or wedge bonds. For best RF performance, use of 150 - 200 μ m length of wedge bonds is advised. Single Ball bonds of 250-300 μ m though acceptable, may cause a deviation in RF performance.



GaAs MMIC devices are susceptible to Electrostatic discharge. Proper precautions should be observed during handling, assembly & testing.

All information and Specifications are subject to change without prior notice.